



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/734,467	12/11/2000	Gerhard Beitel	INF-P80224 US	5119

7590

08/07/2003

LERNER AND GREENBERG, P.A.
POST OFFICE BOX 2480
HOLLYWOOD, FL 33022-2480

EXAMINER

BROPHY, JAMIE LYNN

ART UNIT

PAPER NUMBER

2822

DATE MAILED: 08/07/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application N .

09/734,467

Applicant(s)

BEITEL ET AL.

Examiner

J. L. Brophy

Art Unit

2822

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 16 June 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-35 is/are pending in the application.
- 4a) Of the above claim(s) 8-10, 14, 16, 18 and 25-35 is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-3, 7, 11-13, 15, 17 and 19-23 is/are rejected.
- 7) ☒ Claim(s) 4-6 and 24 is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 11 December 2000 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- 1) ☐ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____.
- 4) ☐ Interview Summary (PTO-413) Paper No(s). _____.
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____.

DETAILED ACTION

This office action is in response to the amendment filed 6/16/03.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1-3, 7, 11-13, 15 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kawakubo et al (5,952,687) in view of Azuma et al (5,708,302).

Kawakubo et al teach a method that comprises providing a prestructured substrate 1;

Applying to the prestructured substrate a precious metal 13 to serve as a bottom electrode; and

Polishing the precious metal 13.

See, for example, Figs. 4B to 4D and 6 and accompanying text.

However, Kawakubo et al do not teach that the bottom electrode is formed by applying a precious metal and a donor material and subjecting the layers to a heat treatment.

Azuma et al teaches a method for forming a bottom electrode that comprises forming a Ti or Ta (donor material) layer 34 followed by forming a Pt (precious metal) layer 36; subjecting the layers to heat treatment at a temperature of between

Art Unit: 2822

approximately 450 °C and approximately 1000 °C (col. 8, lines 37-40), such that the Ti or Ta layer 34 diffuses into the Pt layer and an alloy layer 38 is produced, wherein the thickness of the donor material is selected such that during heat treatment the donor material essentially diffuses completely into the precious metal (col. 5, lines 11-14).

See Fig. 1 and accompanying text.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the method disclosed by Kawakubo et al by forming the bottom electrode using the method taught by Azuma et al because a person of ordinary skill in the art at the time the invention was made would have been motivated to use the method taught by Azuma et al in order to form a bottom electrode that adheres well to the underlying layers and does not have short-inducing surface irregularities (see Azuma et al, col. 1, lines 53-59).

Re claim 17, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to optimize and select an appropriate concentration of the donor material in the alloy layer. The selection of parameters such as energy, power, concentration, temperature, time, depth, thickness, etc., would have been obvious and involve routine optimization which has been held to be within the level of ordinary skill in the art. "Normally, it is to be expected that a change in temperature, or in concentration, or in both, would be an unpatentable modification. Under some circumstances, however, changes such as these may be impart patentability to a process if the particular ranges claimed produce a new and unexpected result which is different in kind and not merely degree from results of prior art...such ranges are termed

Art Unit: 2822

'critical ranges' and the applicant has the burden of proving such criticality...More particularly, where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation". *In Re Aller* 105 USPQ 233, 235 (CCPA 1955). See also MPEP 2144.05.

Claims 19-21 and 23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kawakubo et al in view of Azuma et al as applied to claims 1-3, 7, 11-13 and 15 above, and further in view of Russell et al (6,395,194).

Kawakubo et al in view of Azuma et al teach a method that comprises forming a precious metal layer and a donor material layer, performing a heat treatment, and performing CMP to form a bottom electrode.

However, Kawakubo et al in view of Azuma et al do not specifically teach the composition of the CMP slurry.

Russell et al teach a CMP slurry for polishing a precious metal layer that comprises water (col. 3, line 7), abrasive particles (col. 4, line 65 through col. 5, line 19), at least one oxidant (col. 5, lines 25-29) and at least one stabilizer (col. 5, lines 28-30), wherein Al_2O_3 particles or SiO_2 particles having a size of approximately 50-300 nm are used as the abrasive.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the method disclosed by Kawakubo et al in view of Azuma et al by using a CMP slurry composition such as that taught by Russell et al because a person of ordinary skill in the art at the time the invention was made would

Art Unit: 2822

have been motivated to use the slurry taught by Russell et al in order to selectively remove the noble metal layer during CMP (see Russell et al, col. 2, lines 29-33).

Claims 19, 20 and 22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kawakubo et al in view of Azuma et al as applied to claims 1-3, 7, 11-13 and 15 above, and further in view of Kirlin et al (5,976,928).

Kawakubo et al in view of Azuma et al teach a method that comprises forming a precious metal layer and a donor material layer, performing a heat treatment, and performing CMP to form a bottom electrode.

However, Kawakubo et al in view of Azuma et al do not specifically teach the composition of the CMP slurry.

Kirlin et al teach a CMP slurry for use in a capacitor structure that comprises water, Al_2O_3 or SiO_2 abrasive particles and at least one oxidant, wherein the oxidant is H_2O_2 (col. 5, lines 16-25).

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the method disclosed by Kawakubo et al in view of Azuma et al by using a CMP slurry composition such as that taught by Kirlin et al because a person of ordinary skill in the art at the time the invention was made would have been motivated to use the slurry taught by Kirlin et al in order to effectively remove the metal and dielectric materials that are commonly used in capacitor structures (see Kirlin et al, col. 4, lines 11-22).

Allowable Subject Matter

Claims 4-6 and 24 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is an examiner's statement of reasons for allowance: none of the references of record teach all of the process limitations as claimed. Specifically, re claims 4 and 6, none of the references teach a method that comprises applying several layers of the precious metal alternately with the donor material, in combination with the other claim limitations. Re claim 5, none of the references teach a method that comprises applying the precious metal before applying the donor material, in combination with the other claim limitations. Re claim 24, none of the references teach a CMP slurry that comprises polyacrylic acid as a stabilizer, in combination with the other claim limitations.

Response to Arguments

Applicant's arguments filed 6/16/03 have been fully considered but they are not persuasive.

Applicant argues (middle of p. 18 of arguments filed 6/16/03) that layer 34 in the Azuma et al reference is not a precious metal layer. As clearly pointed out in the above rejection, layer 34 of the Azuma reference is a Ti or Ta layer, which corresponds to the "donor material" layer of the present application. Applicant further argues that Azuma et al do not teach a "donor material containing an additive". However, layer 34 of the

Art Unit: 2822

Azuma et al reference is made of Ti or Ta, thereby forming a donor material layer that consists essentially of the additive (see claim 2 of the present application).

In response to applicant's argument that a person skilled in the art who uses the method according to Kawakubo would not consider the method according to claim 1 useful (first full paragraph on p. 19 of arguments), the fact that applicant has recognized another advantage which would flow naturally from following the suggestion of the prior art cannot be the basis for patentability when the differences would otherwise be obvious. See *Ex parte Obiaya*, 227 USPQ 58, 60 (Bd. Pat. App. & Inter. 1985). The motivation for combining Kawakubo et al in view of Azuma et al in the 35 USC § 103 rejection above is clearly stated. Applicant has failed to argue why the motivation provided in the rejection is not sufficient.

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

Art Unit: 2822

the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to J. L. Brophy whose telephone number is (703) 308-6182. The examiner can normally be reached on M-F (8:00-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (703) 308-4905. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9318 for regular communications and (703) 872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

J.L.B.

jlb

July 29, 2003


AMIR ZARABIAN
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800